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Research in solar cell technology has accelerated the development of thin-film solar cells. In particular, the development of high efficiency, low cost, and flexible solar cells is a major goal. This paper reports on the development of a new class of solar cells based on the combination of silicon and organic materials. The combination of silicon and organic materials can lead to high efficiency solar cells with low cost and flexibility. © 2006 American Vacuum Society. [DOI: 10.1116/1.2209995]

$Cu_{1-x}Ga_xSe_2$ solar cell absorption maxima increase with increasing efficiency. The high degree of intermixing in the system has been demonstrated by detailed gain-loss analysis. The effect of the carrier concentration and the high atomic concentration, combined with the nanoscale intermixing, are investigated in detail. © 2006 American Vacuum Society. [DOI: 10.1116/1.2209995]

I. INTRODUCTION

$Cu_{1-x}Ga_xSe_2$ (CIGS) is an important thin film solar material. Notable record efficiencies of nearly 20% (Ref. 1) are based on the all-inorganic CIGS device, which is formed by the intermixing of the two materials.² This

Gi en ch a áie f ed m del , a e f ech-
 ni e i needed be CIGS ichi me and elec -
 a ic i h nan cale en i i i in d e al a e he dif-
 fe en mehani m . N me die ha e been e f med
 n CIGS and ela ed em add e ing g ain chemi and
 m h l g .^{14 17} In e cen a e¹⁸ e e ed n he
 d e c mea men f elemen al c m i n f he indi-
 id al g ain and he b nd áie . We h ed ha c e
 c m i i n a CIGS GB de e a e , me im e b alm a
 fac f 2, and ha he k f nc i n de e a e b e e al
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 n, en ial di ib i n, and elec nic fea e f GI
 and GB n l áhigh ac m (UHV) clea ed CIGS e -
 ec i n face . B em l ing A g e elec n ec c
 (AES), ec nd á elec n k e h ld (SET) mea men ,
 ca h d l mine cence ec c (CLS), and ec nd á
 i h ma ec c (SIMS) e c n m he he e ical
 edic i n f the h le bá áie a GB de t C de cienc
 and e n he c m le m h l gical e f hi
 ma e ial.

II. EXPERIMENTAL DETAILS

The am le died in hi k e e g n n a da
 lime gla b áe i h á M back e n ac ing a k ee
 e ce de áibed el e h e. The la e hickne e
 e 1.5 2.0 m f CIGS and ~0.7 m f M . The
 am le had f diff e n n minal C /(In+Ga) á i f
 0.78, 0.85, 0.93, and 0.99, and a Ga/(In+Ga) á i f 0.30,
 a de e mined b ind c i el c led la ma ec c .
 In d e b ain high- ali clea ed e ec i n , he
 f ll ing ced e a im lemen ed. F e , he gla back-
 ide fa am le a hinned b g inding t b ing he am le
 hickne ~1 mm. The back ide e e hen n ched i h
 a diam nd a a de h f ~500 m. An ~300 hick Ni
 la e a de i ed n he back ide e e a n elec ical
 c n ac ed ce áá g ing de elec n-beam b mb á d-
 men . The am le e e clea ed in ac m i i mea men
 in an ambien e e f ~10⁹ T and then imme-
 dia el an f e d he main chamb á i h e e f
 ~10¹⁰ T . The *in situ* mea men e e e f med em-
 l ing a JEOL 7800F canning elec n mi e be
 e i ed i h a hemi h e ical elec n analm338, heef9.978 f-272.1a-27

both the negative and positive angles $\approx 20^\circ$. The angular intensity change detected near the surface, care is taken to minimize the GB width in the face at normal incidence.

Figure 2 shows the high resolution GB of the sample in the minimal $C/(In+Ga)$ ratio of 0.99. The thickness difference between the sample and the analyzer (E) is 1 eV. The distance from each GB. Negative distance indicates initial measurement in the gain, origin at the GB, and positive distance from the band in an adjacent gain. The given decrease in the thickness from 250 to 500 meV for gain bands 1 and 2, respectively. Other gain bands show similar decrease although decrease can be identified from 0 to 500 meV. The decrease in the measurement is typically in the range of ~ 200 meV. The decrease in the initial area is also similar to the scanning Kelvin probe measurement of the band structure of the chalcogenide GB as reported in Ref. 15 and 16, where the authors found an initial decrease (downward band bending) at the GB of 100 to 200 meV, which is again comparable to the change reported here. This indicates the importance of UHV in aiding the determination of the chemical composition in an analytical technique such as the scanning Kelvin probe.

C. CLS and SE Imaging

CLS results were obtained from the sample in the minimal bulk $C/(In+Ga)$ ratio of 0.99. This sample was cleaved *ex situ* and then immediately loaded into the vacuum chamber. The data were acquired using high resolution electron spectroscopy and analyzed using a least-squares fitting procedure. The CLS data were obtained as well. Practically all the detected emission peaks, however, were in the range of the gain bands. Figure 3 shows the sample surface after the cleavage from different regions of the sample: the emission peaks at 1.12, 1.16, and 1.19 eV are seen in the spectra. The feature change in intensity

at different locations in the sample. The low energy tail in the spectra is likely due to surface defects and disorder in the sample.

CLS imaging at different electron energies for the sample shows the lack of uniformity. Figure 4 shows the CLS image obtained using the scanning SE image. The high energy peak is localized in intensity near the

CIGS GB.³ Indeed, the 25%–50% decrease of C concentration in the back interface in good quality agreement with the prediction of Jaffe and Zeng.¹⁰ While the decrease in the back interface of the chemical bonding at GBs is not known, the data show that the GBs are similar to free surface and a noticeable increase in the gain mainly from chemical bonding between them. GBs are commonly deleted at back-back Schottky barriers, and this is consistent with an attachment of the GBs to the hillocks in the back interface.

D. SIMS ANALYSIS

A SIMS depth profile of the sample is shown in Fig. 6. The data indicate a Ga gradient through the sample consistent with the standard growth conditions and the stoichiometry of the CLS. The Ga signal is about 50% of the In signal. A Na increase of an order of magnitude (from a signal of 10–200 counts to 10 counts) near the M back interface is typical and may be determined by the change in the M back interface. The concentration of the Ga is also determined. The depth profile of the Ga is different from In and Ga in the M layer, indicating the back interface. Imaging of the In and Ga signal in the back interface shows a homogeneous distribution of the In and Ga signal in the back interface. The Ga signal is much larger than the In signal in the back interface (120 nm), the typical grain size (~1 μm), of the M layer is about 90°. The Na signal is also visible in the back interface of the CIGS layer in the M layer.

IV. DISCUSSION

The AES results of the CIGS samples measured at different temperatures are discussed in the following section.

vele an ai ic n he CIGS la d i e ie e fied a
la ge n mb e t f mea t vemen t ad ai t regi n f t he
am le .

The b e d SET inh m genei ie e e v ng e han
h e e hibid in he AES and CLS mea vemen . S t me-
t ime g ain- g ain en ial change e e t igni can t
t ha he b c v ed an t change f en ial a he GB . We
t a v t b ed he e b e a i n e e al fac v : (i) a ia i n
in g ain- g ain t ichi me t , (ii) en ial diff e ence t be-
t een g ain face t i h di t imil a d t all g a hic v ien a-
t i n (c n i t en t i h t he v e v ed Kel t in v be v e l t ²³ⁱⁱ

de led GB interface can inhibit the recombination, generating high efficiency. Our results have demonstrated that the Fermi level decreases with increasing GB concentration, which is a band field effect. The carrier recombination is inhibited by the built-in electric field of the GB and the effective recombination rate is reduced. We found that the non-radiative recombination rate is high, which can account for the low efficiency of the main emitting CIGS nitride LEDs. Our results have demonstrated that the main emitting CIGS nitride LEDs, UHV grown, and the carrier recombination rate is reduced.

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